Progress in Two-Plate Ion Trap Mass Analyzers

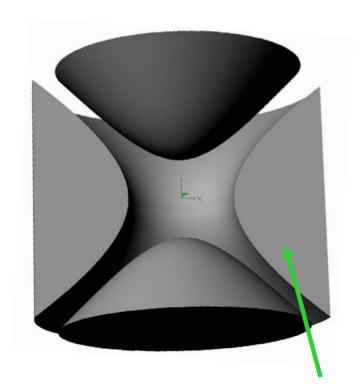


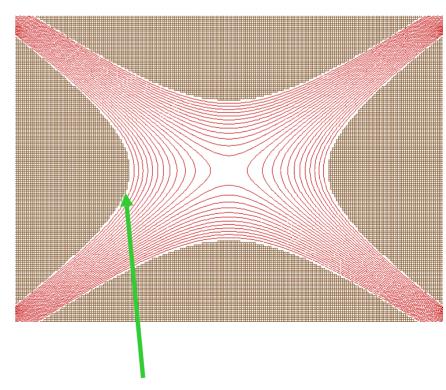
Daniel E. Austin

Coauthors: Zhiping Zhang, Ying Peng, Miao Wang, Brett Hansen, Hannah Quist, and Aaron Hawkins Brigham Young University, Provo, Utah

addiapolar i oteritiai Distributions

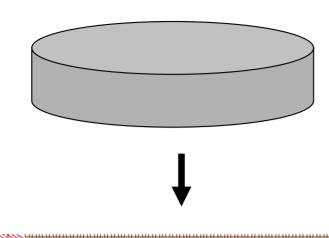
- Potential varies quadratically in x,y or in r,z
- Electric field is linear over the same variables
- Metal electrodes represent equipotential boundary conditions
- RF applied to metal electrodes produces quadrupolar field
- Time-varying quadrupolar fields allow trapping, mass analysis



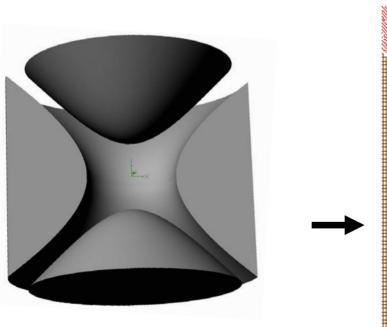


Hyperbolic surfaces produce quadrupolar fields

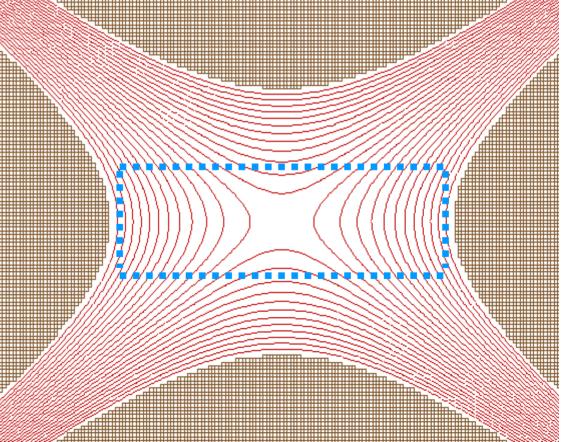
oundary Conditions efine Fields



New boundary conditions: cylindrical surface with quadratic potential functions fields inside are the same!

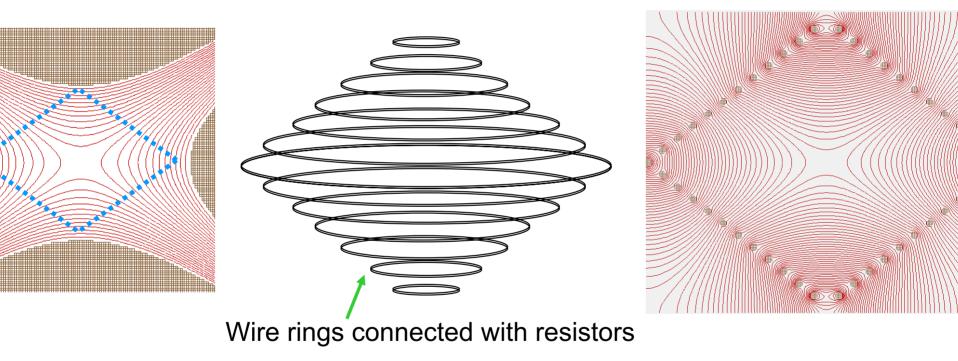


Equipotential boundary conditions: three hyperboloidal electrodes



Example: Wang's conic section trap

- Quadrupolar field made using two cones of wire rings
- Potential between rings varies linearly
- Resulting field is (approximately) quadrupolar



In the limiting case of an infinite number of rings this resembles a resistive materia

However, good fields are obtained with only a few rings due to averaging

Two-Plate Ion Traps

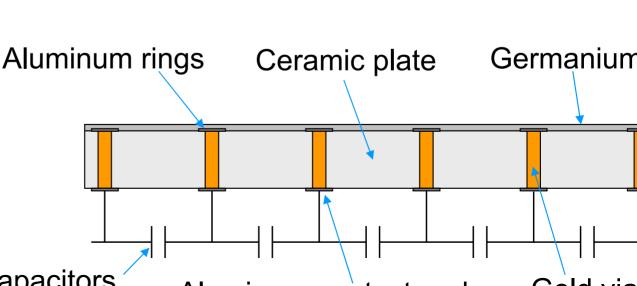
ach plate contains series of hographically-defined metal vires", overlaid with resistive ermanium

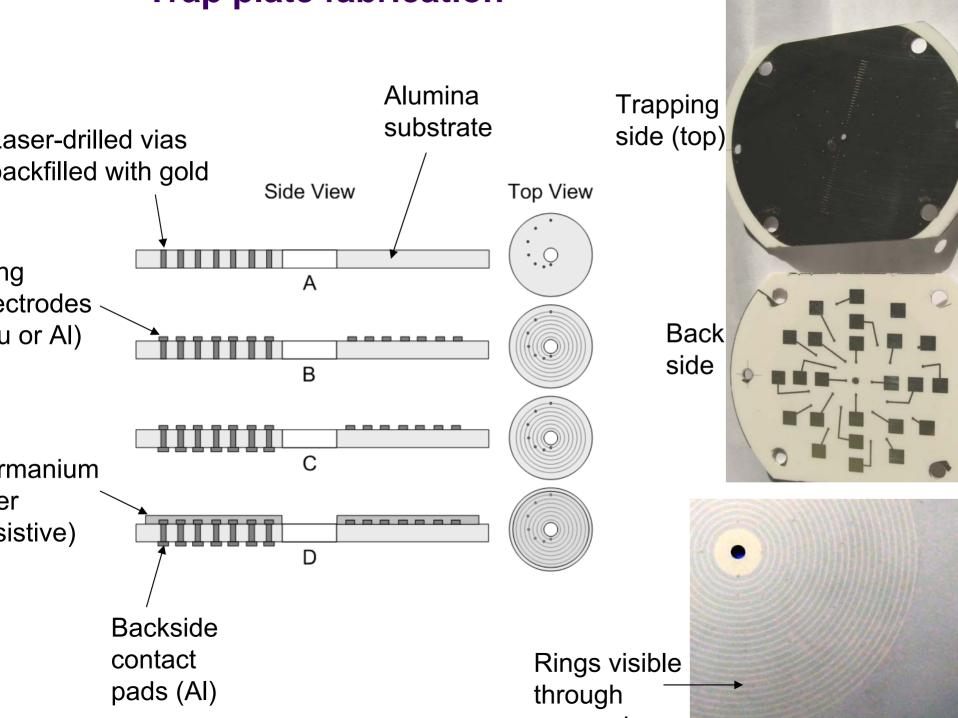
ifferent RF amplitudes applied each "wire" produce trapping elds

Canacitors

Capacitive voltage divi C₁ C₂ C₃ C₄ C₅

nm germanium er prevents arge build-up and ovides continuous rface potential





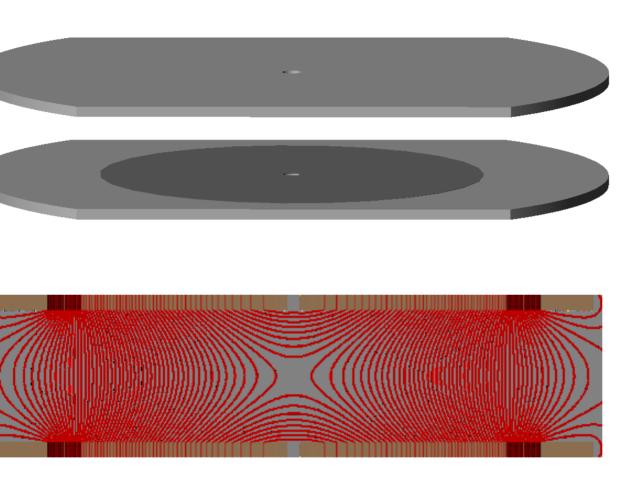
Three-fold Motivation Behind This Work:

Explore Electric Fields
 Independently adjust higher order multipoles

Novel Trap Geometries Possible
 Paul trap, toroidal, coaxial, others

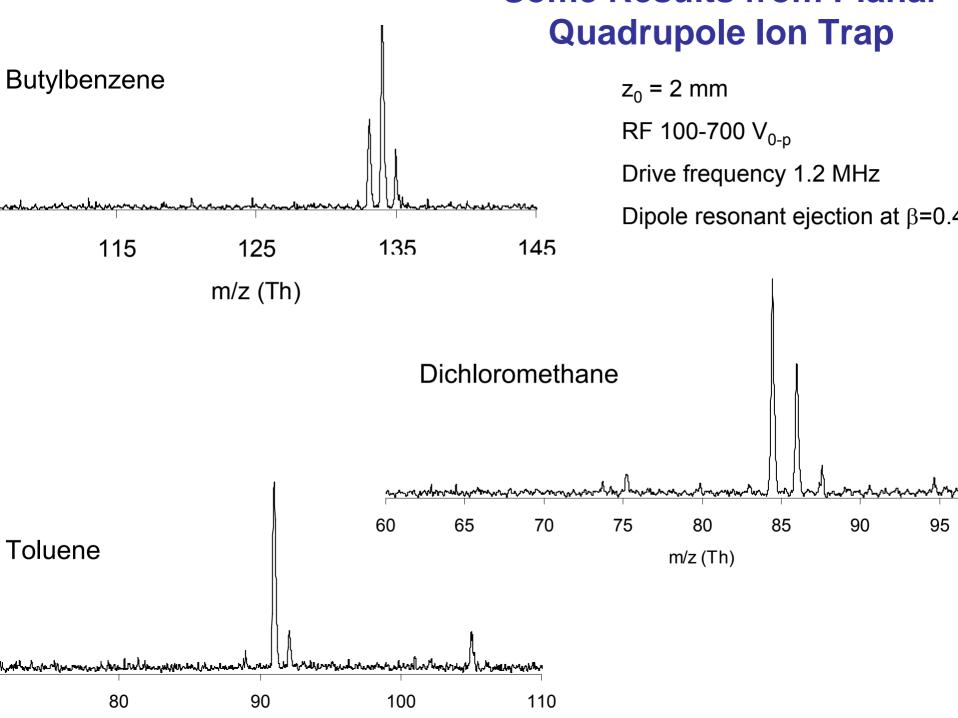
Mass Analyzer Miniaturization
 Combines microlithography with accurate electric fields

A Quadrupole Ion Trap made using microfabricated electrodes





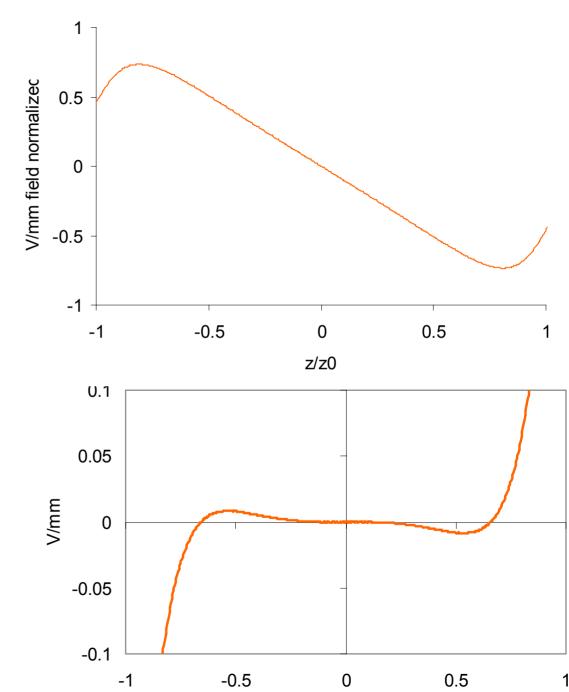
Made using two plates, each lithographically imprinted with concentric ring electrodes, coated with germanium



Axial electric field

igher order components axial field

ield components easily djustable by varying otentials on rings



Modifying Higher-order Multipoles

All cylindrically symmetric potentials can be expressed as:

$$\Phi(\rho, \theta, \phi, t) = \Phi_0(t) \sum_{l=0}^{\infty} A_l \left(\frac{\rho}{r_N}\right)^l P_l(\cos \theta)$$

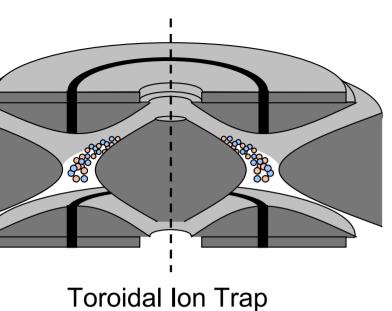
ariables: position and voltage on each ring, plate spacing, hole size

quadrupole (l=2), hexapole (l=3), octopole (l=4), etc.

or a given physical design, superposition allows us to combine multipole expansi

or a given physical design, superposition allows us to combine multipole expansio esulting from each ring:

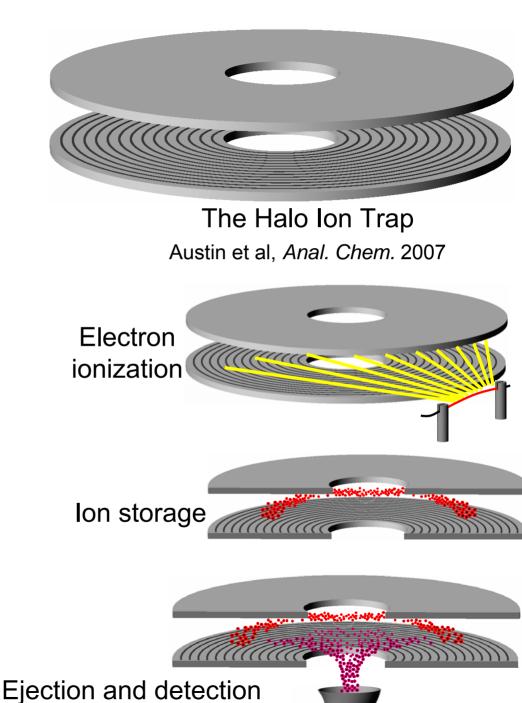
	Ring 1	Ring 2	Ring 3	 Ring m
A_2	-0.100032	0.103965	0.155169	 A_2m
A_4	0.568701	0.330117	0.155211	 A_4m
A_6	0.352728	-0.001885	-0.071216	 A_6m
A_8	-0.360680	-0.170844	0.146052	 A_8m
•	:	:	:	
Δ .	Δ 1	Δ 2	Δ 3	Δ m



Lammert et al, *IJMS*, 2001.

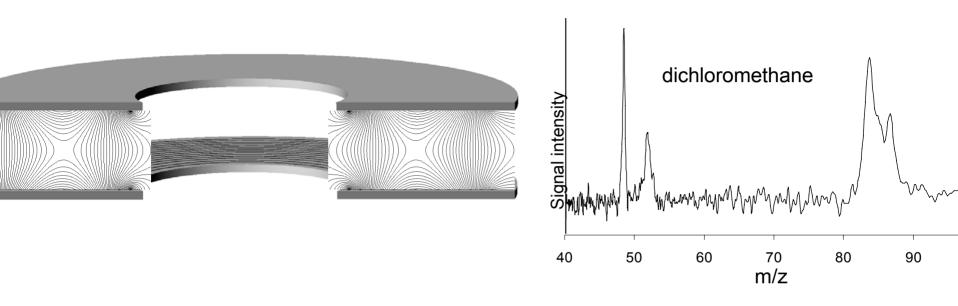
ons trapped, stored in a torus (ring)
Slits in endcaps for ion ejection and ectron beam

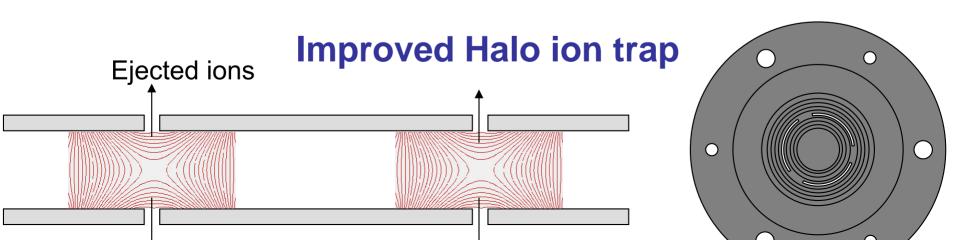
_arge storage capacity

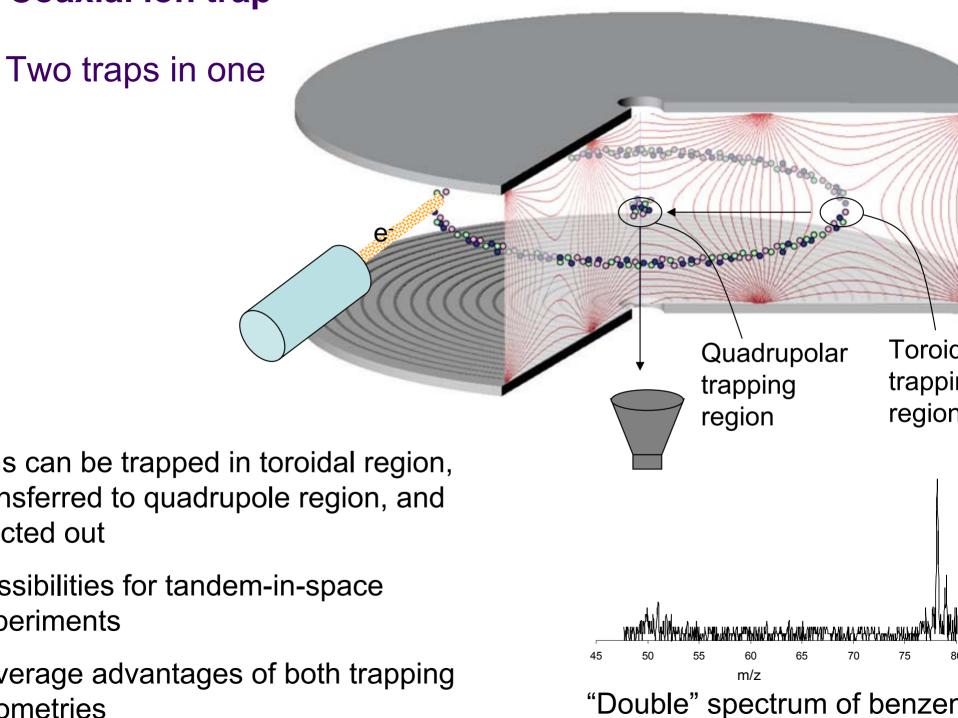


Original Halo ion trap

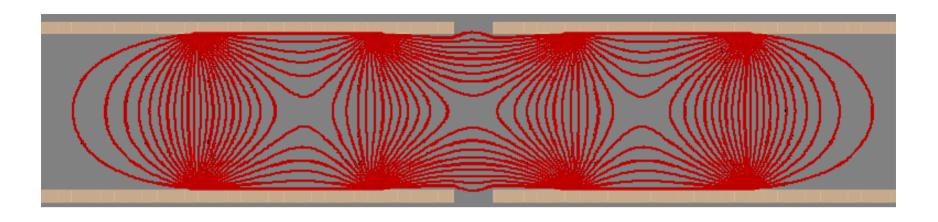
Radial ejection



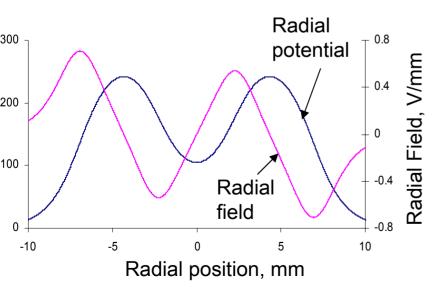


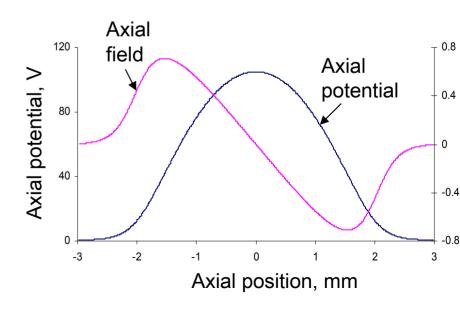


isopotentiai iines iii the coaxiai ion trap



Radial and axial potentials and fields





mass Analyzer miniaturization

otivation

Smaller mean free path → higher operating pressure, smaller pump

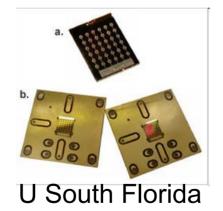
Reduced power → smaller batteries

Instrument portability

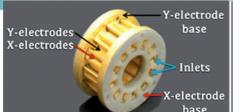
Lower cost

Why ion traps?

- Higher tolerance to pressure
- Amenable to GC-MS, LC-MS
- Tandem MS capabilities
- Frequency, voltages scale favorably



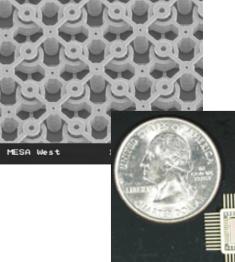






UNC







(esp. ion traps)

aking accurate fields:

Machining / fabrication accuracy

Electrode alignment

Surface roughness

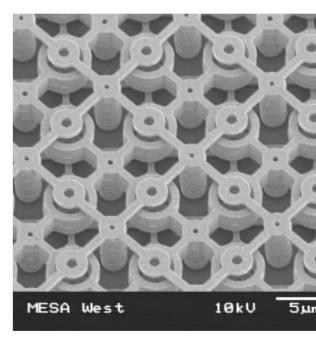
ractical issues:

Reduced access for ions or ionizing radiation

Reduced ion count (space charge)

Keeping arrayed traps parallel

Insufficient stopping distance to trap ions



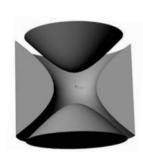
from Austin et al, JASMS 200

3 dimensions of 2?

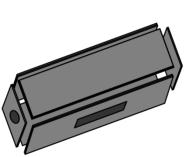
urrent paradigm: take a 3-dimensional structure (the ion trap), scale it down smalle ith minor simplifications in geometry. Essential 3-D device structure remains.

icrofabrication technology produces 2½ dimensional devices

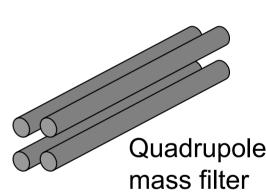
ow do we exploit the high precision of 2 dimensions?



Quadrupole ion trap or Paul trap

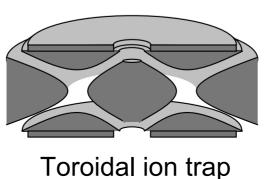


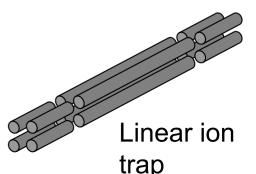
Rectilinear ion trap

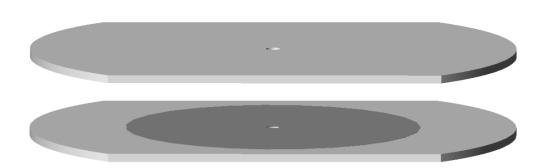












- Surface planarity, roughness controlled to within tens of nanometers
- Uses microfabrication methods
- Sub-micron mechanical tolerances
- Alignment simplified: only two pieces
- Larger access area for ionization or pumping
- Sturdy—no tiny parts as there are with MEMS
- Ceramic disks can be any thickness—greater strength
- The two plates have identical potential distributions, so capacitance does not increase as they are moved together
- Economy of scale—potentially lower cost than machined electrodes

Austin Group

BYU Microfabrication Lab

Collaborators

Dr. Zhiping Zhang

Prof. Aaron Hawkins

Miao Wang

Ying Peng

Brett Hansen

Prof. Milton Lee

Terik Daly

Seth Call

Dr. Steve Lammer



...And who is paying for it

Funding on this project from NASA

